

## Photocatalytic Nanostructuring of Graphene Guided by Block Copolymer Self-Assembly - DTU Orbit (09/11/2017)

### Photocatalytic Nanostructuring of Graphene Guided by Block Copolymer Self-Assembly

Nanostructured graphene exhibits many intriguing properties. For example, precisely controlled graphene nanomeshes can be applied in electronic, photonic, or sensing devices. However, fabrication of nanopatterned graphene with periodic superlattice remains a challenge. In this work, periodic graphene nanomesh was fabricated by photocatalysis of single-layer graphene suspended on top of TiO<sub>2</sub>-covered nanopillars, which were produced by combining block copolymer nanolithography with atomic layer deposition. Graphene nanoribbons were also prepared by the same method applied to a line-forming block copolymer template. This mask-free and nonchemical/nonplasma route offers an exciting platform for nanopatterning of graphene and other UV-transparent materials for device engineering.

#### General information

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